

SHIGA7.048APC

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JAP2004/015504 29 APR 2006 PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Hada et al.
Appl. No. : U.S. National Phase of
PCT/JP2004/015504
Filed : Herewith
For : RESIST COMPOSITION AND
METHOD FOR FORMING
RESIST PATTERN
Examiner : Unassigned
Group Art Unit : Unknown

CERTIFICATE OF MAILING

I hereby certify that this correspondence and all marked attachments are being deposited with the United States Postal Service as first-class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on

April 20, 2006

(Date)

Nell S. Bartfield, Ph.D., Reg. No. 39,901

PRELIMINARY AMENDMENT

Mail Stop PCT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Prior to examination of the above-referenced application, please enter the following amendments:

Amendments to the Specification begin on page 2 of this paper.

Amendments to the Claims begin on page 3 of this paper.

Remarks begin on page 5 of this paper.